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Microstructure of gas flow sputtered thermal barrier coatings: Influence of bias voltage

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Manuscript Cover Page**ABSTRACT NUMBER:** 325**PRESENTATION IDENTIFICATION NUMBER:** A2-1-9**TITLE OF PAPER:** Microstructure of gas flow sputtered thermal barrier coatings: Influence of bias voltage**PRESENTING AUTHOR at the conference:** Nils Rösemann**MAILING ADDRESS:** Langer Kamp 8, 38106 Braunschweig, GERMANY**TELEPHONE:** +49 531 391 3063**FAX:** +49 531 391 3058**E-MAIL:** n.roesemann@tu-bs.de**CORRESPONDING AUTHOR:** as presenting author

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